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APPLICANT				APPLICANT(S) Se Hwan KIM and Jong Hyun WOO					
	(PTO-1	1449)	FILING DATE July 30, 2003		GROUP To be assigned				
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.